

	Sep.5(Sun)	Sep.6 (Mon)							Sep.7 (Tue)							Sep.8 (Wed)							Sep.9 (Thu)								
	MO Hall (Room A)	Room B	Room C	Room D	Room E	Room F	3F Lobby	1F Lobby	MO Hall (Room A)	Room B	Room C	Room D	Room E	Room F	3F Lobby	1F Lobby	MO Hall (Room A)	Room B	Room C	Room D	Room E	Room F	3F Lobby	1F Lobby	Technical Visit						
8:45																															
9:00		MO Hall OPEN														B-5 Novel Method for Medical and Biological Measurement C-6 Machine Vision and Image Processing D-5 Intelligent Micro and Nano Metrology (2) E-5 Nano Photonics in Intelligent Measurement F-5 Intelligent Measurement Algorithm and Simulation(1)							Tour1 Start	Tour2 Start							
9:30		OPENING Ceremony														B-6 X-Ray Application for 3-D Measurement C-6 Optical Measurement for Geometrical Quantity Evaluation (4) D-6 Pre-, In-, Post process measurement (2) E-6 Geometrical Product Specification and Form Test F-6 Intelligent Measurement Algorithm and Simulation(2)							Bus	Bus							
10:00		Plenary1 Tilo Pfeifer														Break															
10:30		Break														Break															
11:00		Plenary2 Richard Leach							B-3 Optical Measurement for Geometrical Quantity Evaluation (2) C-3 Pre-, In-, Post process measurement D-3 Quality Control E-3 CMM Metrology (2) F-3 Uncertainty Evaluation and Traceability (2)							Industrial Exhibition Information Desk							Technical visit Panasonic	Technical visit Shimadzu							
11:30		Plenary3 Kiyoshi Takamasu														Break															
12:00									Registration							Closing Ceremony															
12:30		Lunch							Lunch							Lunch							Lunch	Lunch							
13:00																															
13:30																							Bus	Bus							
14:00		B-1 3-D Surface Texture and its Micro Characteristics C-1 Optical Measurement for Geometrical Quantity Evaluation (1) D-1 Advanced Optoelectronic Sensors and Instrument(1) E-1 Ultra Precision Length Measurement F-1 Macrogeometri c Features and Uncertainty Evaluation							Keynote3 Seung-Woo KIM Keynote4 Sarwat Zahwi							Poster Session Industrial Exhibition							Registration								
14:30		Keynote1 Yunt Chugui														Coffee Break 30 minutes															
15:00		B-2 Gear Metrology C-2 MEMS/MOEMS application in Measurement field D-2 Advanced Optoelectronic Sensors and Instrument(2) E-2 CMM Metrology (1) F-2 Uncertainty Evaluation and Traceability (1)														Coffee Break 30 minutes															
15:30	Registration															B-4 Intelligent Micro and Nano Metrology (1) C-4 Analytical Method for Uncertainty Evaluation D-4 Optical Measurement for Geometrical Quantity Evaluation (3) E-4 CMM Metrology (3) F-4 Tolerance, Testing, Test Planning							Industrial Exhibition Registration and Information Desk							Bus	Bus
16:00																															
16:30																															
17:00																															
17:30	Welcome Reception																														
									Bus Convention center to the Senni Hankyu hotel Banquet																						